#### Characterisation of optical elements for soft X-ray microprobing and microscopy

#### **Matthew Shand**

Silson Ltd.

(King's College London)

## Talk outline

#### **Experimental outline**

Microfocus X-ray source description

#### Microprobing

- Microstructured Optical Arrays (MOAs)
- Optical Characterisation
  Zone plates

#### Microscopy

- Microscope X-ray Invitro (McXI)

  - Characterisation results

### The microfocus soft X-ray source



- Electron bombardment X-ray source
- Interchangeable target materials AI ( $K_{\alpha}$ =1.477 keV), C (K=0.277 keV)
- ≈200 µm diameter X-ray source

# Microfocus source coupled to detector



#### Microstructured Optical Array (MOA)



- Developed as part of the Smart X-ray Optics consortium
- Reflections from an array of channels contribute to focused spot
- Single and double reflections considered along X-ray path
- Active control of focal length
- Radiobiological microprobe experiments (2  $\mu$ m diameter focused spot of Ti K<sub>a</sub> X-rays from a 5  $\mu$ m X-ray source)

R. Willingale et al. "Active Microstructured Optical Arrays of Grazing Incidence Reflectors". X-Ray Optics and Instrumentation (2010)

# Manufacture of MOAs TMAH

#### (Bosch Process)

DRIE

# (Alkaline solution)



20 µm

#### Roughness ≈ 8 nm RMS (min.)



70 µm

#### Roughness $\approx$ 1.5 nm RMS

### Spider MOAs

- For an appropriate focal length,  $R \approx 50 \text{ mm}$ 
  - Not achievable using simple designs (R = 420 mm min.)
- Spider-like levers etched into silicon substrate enhance the curvature across the active area
- Mechanical testing of spider MOAs indicates R=30 mm



# Simulation of MOA focusing properties

- Simulation of focusing effect for a MOA array
- X-rays reflected (red pixels) by each channel contribute to a common focused spot at  $z_d=z=160$  mm
- Focused spot is isolated from unreflected (blue) X-rays by central stop



# Experimental method for characterisation of MOAs



- Displacement of MOA channels from optical axis separates reflected radiation from unreflected "background"
- Ideal for use with microfocus X-ray source.

# Simulation of MOA displacement $(y_{T})$



# Experimental characterisation of MOAs













TMAH etched MOA Broadband Al X-rays z=z'=300 mm

# Experimental characterisation of MOAs



*z=z*′=300 mm

### Position stability of DRIE vs TMAH

DRIE etched MOA

• Symmetrical about either side of optical axis





#### TMAH etched MOA

• Shift in reflected position occurs due to taper in channel structure

STSM – Characterisation of a prototype soft X-ray microscope

- Autumn 2009
- Aim: To characterise the performance of the McXI-I (Microscope X-ray In-vitro) prototype soft X-ray microscope (www.mcxi.eu)
- In collaboration with NANO-UV
- Additional work has since been conducted at KCL, to characterise the microscope using the microfocus Xray source described

#### McXI-I microscope



## Zone Plate (ZP) characterisation



Typical Au electroplated ZP (d<sub>n</sub>=100 nm) Silson Ltd.

3 µm

1<sup>st</sup> order diffraction pattern produced by ZP (C, Al)



#### Diffraction pattern of Condenser ZP



Broadband X-rays produced by C target

## Conclusions

- A microfocus X-ray source has been developed at KCL for characterisation of soft X-ray optics
- This source has been used to characterise unactuated MOAs, and shows good comparison with simulation
  - The performance of actuated MOAs may now be considered in a similar manner
- Initial tests of the performance of the McXI-I microscope have also been performed using this Xray source

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Development of McXI-II microscope

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